

L19 ANSWER 1 OF 3 CAPLUS COPYRIGHT 2005 ACS on STN
 AN 2003:853147 CAPLUS
 DN 139:339085
 ED Entered STN: 31 Oct 2003
 TI Electrodeposition and coated articles with uniform coating thickness
 IN Shimazaki, Akihiko; Midokawachi, Susumu; Tominaga, Akira; Nishiguchi, Shigeo; Nemoto, Yukihiro; Kato, Kiyoshi
 PA Kansai Paint Co., Ltd., Japan
 SO Jpn. Kokai Tokkyo Koho, 12 pp.
 CODEN: JKXXAF
 DT Patent
 LA Japanese
 IC ICM C25D013-06
 ICS C09D005-44; C09D163-00; C09D175-04
 CC 42-2 (Coatings, Inks, and Related Products)
 FAN.CNT 1

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI JP 2003306796	A2	20031031	JP 2002-58570	20020305 <--
PRAI JP 2001-65664	A	20010308		
JP 2002-34905	A	20020213		

CLASS

PATENT NO.	CLASS	PATENT FAMILY CLASSIFICATION CODES
JP 2003306796	ICM C25D013-06	ICS C09D005-44; C09D163-00; C09D175-04

AB In the electrodeposition of cationic electrodeposition coatings, amts. of electricity necessary for the coatings to start deposition is 100-400 C/m². The process is suitable for coating on automotive bodies. Thus, a base resin varnish was prepared by reacting Epikote 828EL (epoxy resin) with bisphenol A, further reacting with liquid HCHO-PhOH-m-xylene copolymer, diethanolamine, and diethylenetriamine ketimine, and mixing with Bu Cellosolve. A hardener comprised a blocked polyisocyanate prepared by reacting Cosmonate M 200 (crude MDI) with 2,2-dimethylolbutanoic acid in a MIBK/ethylene glycol monobutyl ether mixture, further reacting with propylene glycol. A cationic electrodeposition coating comprised an emulsion containing the base resin varnish and the hardener, a pigment paste, and deionized water and gave a uniform layers on Zn phosphate-treated SPCC steel plate.
 ST xylene formaldehyde resin modified epoxy electrodeposition coating;
 IT Crosslinking agents
 (blocked aromatic polyisocyanates; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
 IT Electrodeposits
 (cationic; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
 IT Phenolic resins, uses
 RL: IMF (Industrial manufacture); RCT (Reactant); TEM (Technical or engineered material use); PREP (Preparation); RACT (Reactant or reagent); USES (Uses)
 (epoxy, xylene-based; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
 IT Electrodeposition
 (isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
 IT Epoxy resins, uses
 RL: IMF (Industrial manufacture); RCT (Reactant); TEM (Technical or engineered material use); PREP (Preparation); RACT (Reactant or reagent); USES (Uses)

- (phenolic, xylene-based; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
- IT Polyurethanes, preparation
RL: IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT (Reactant or reagent)
(prepolymers, polyisocyanates, blocked; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
- IT Polyoxyalkylenes, uses
RL: IMF (Industrial manufacture); RCT (Reactant); TEM (Technical or engineered material use); PREP (Preparation); RACT (Reactant or reagent); USES (Uses)
(reaction products with ϵ -caprolactone, Epikote 828EL, bisphenol A, diethanolamine, and diethylenetriamine ketimine derivs., base resin; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
- IT 5124-30-1, Hydrogenated MDI 79103-62-1, Desmodur W
RL: RCT (Reactant); RACT (Reactant or reagent)
(Me Et ketoxime-blocked; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
- IT 39462-15-2, uses
RL: TEM (Technical or engineered material use); USES (Uses)
(Zn phosphate-treated substrate; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
- IT 50-00-0DP, Formaldehyde, reaction products with bisphenol A, Epikote 828EL, phenol, m-xylene, diethanolamine, and diethylenetriamine ketimine derivs. 80-05-7DP, Bisphenol A, reaction products with Epikote 828EL, formaldehyde, phenol, m-xylene, diethanolamine, and diethylenetriamine ketimine derivs. 108-38-3DP, m-Xylene, reaction products with bisphenol A, Epikote 828EL, formaldehyde, phenol diethanolamine, and diethylenetriamine ketimine derivs. 108-95-2DP, Phenol, reaction products with bisphenol A, Epikote 828EL, formaldehyde, m-xylene, diethanolamine, and diethylenetriamine ketimine derivs. 111-40-0DP, Diethylenetriamine, ketimine derivs., reaction products with bisphenol A, Epikote 828EL, formaldehyde, phenol, m-xylene, and diethanolamine 111-42-2DP, Diethanolamine, reaction products with bisphenol A, Epikote 828EL, formaldehyde, phenol, m-xylene, and diethylenetriamine ketimine derivs. 502-44-3DP, ϵ -Caprolactone, reaction products with polypropylene glycol, Epikote 828EL, bisphenol A, diethanolamine, and diethylenetriamine ketimine derivs. 25085-99-8DP, Epikote 828EL, reaction products with bisphenol A, formaldehyde, phenol, m-xylene, diethanolamine, and diethylenetriamine ketimine derivs. 25322-69-4DP, PP 1000, reaction products with ϵ -caprolactone, Epikote 828EL, bisphenol A, diethanolamine, and diethylenetriamine ketimine derivs. 56743-27-2DP, Dimethylolbutanoic acid, reaction products with bisphenol A, Epikote 828EL, formaldehyde, phenol, m-xylene, and diethylenetriamine ketimine derivs.
RL: IMF (Industrial manufacture); RCT (Reactant); TEM (Technical or engineered material use); PREP (Preparation); RACT (Reactant or reagent); USES (Uses)
(base resin; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
- IT 57-55-6, Propylene glycol, reactions
RL: RCT (Reactant); RACT (Reactant or reagent)
(crude MDI-based polyurethane polyisocyanate blocked with; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
- IT 96-29-7, Methyl ethyl ketoxime
RL: RCT (Reactant); RACT (Reactant or reagent)
(hydrogenated MDI blocked with; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)

IT 616207-82-0P
RL: IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT (Reactant or reagent)
(propylene glycol-blocked; isocyanate-curable xylene resin-modified epoxy cationic electrodeposition coatings for uniform layers)
RN 5124-30-1
RN 79103-62-1
RN 39462-15-2
RN 50-00-0DP
RN 80-05-7DP
RN 108-38-3DP
RN 108-95-2DP
RN 111-40-0DP
RN 111-42-2DP
RN 502-44-3DP
RN 25085-99-8DP
RN 25322-69-4DP
RN 56743-27-2DP
RN 57-55-6
RN 96-29-7
RN 616207-82-0P

L19 ANSWER 2 OF 3 WPIX COPYRIGHT 2005 THE THOMSON CORP on STN
AN 2004-206750 [20] WPIX
DNN N2004-163955 DNC C2004-082559
TI Electrodeposition coating film formation to produce coated material, involves adjusting electric charge for initial precipitation of coating film, to preset value, during coating of cation electrodeposition coating material.
DC A21 A25 A85 G02 M11 X25
PA (KAPA) KANSAI PAINT CO LTD
CYC 1
PI JP 2003306796 A 20031031 (200420)* 12 C25D013-06 <--
ADT JP 2003306796 A JP 2002-58570 20020305
PRAI JP 2002-34905 20020213; JP 2001-65664 20010308
IC ICM C25D013-06
ICS C09D005-44; C09D163-00; C09D175-04
AB JP2003306796 A UPAB: 20040324
NOVELTY - Electrodeposition coating film formation method involves adjusting electric charge for initial precipitation of coating film to 100-400 C/m², during electrodeposition coating of a cation electrodeposition coating material.

DETAILED DESCRIPTION - An INDEPENDENT CLAIM is included for coated material.

USE - For forming electrodeposition coating film, to produce coated material (claimed).

ADVANTAGE - The electrodeposition coated film or the coated material with excellent uniform paint work and rust-proof property, and with restrained film thickness of skin, is produced efficiently and economically, by the electrodeposition coating film formation method. The method improves internal film formability.

DESCRIPTION OF DRAWING(S) - The figure shows the graph of dry weight (mg) of coating material with respect to electric charge (X). (Drawing includes non-English language text).

Dwg.3/4

FS CPI EPI
FA AB; GI
MC CPI: A10-E01; A11-B05A; A12-B01; A12-B01L; G02-A05; M11-G
EPI: X25-R04

L19 ANSWER 3 OF 3 JAPIO (C) 2005 JPO on STN
AN 2003-306796 JAPIO
TI METHOD OF FORMING ELECTRODEPOSITION COATING FILM AND COATED PRODUCT

IN SHIMAZAKI AKIHIKO; MIDOKOCHI SUSUMU; TOMINAGA AKIRA; NISHIGUCHI JIRO;
NEMOTO YUKIHIRO; KATO KIYOSHI
PA KANSAI PAINT CO LTD
PI JP 2003306796 A 20031031 Heisei
AI JP 2002-58570 (JP2002058570 Heisei) 20020305
PRAI JP 2001-65664 20010308
JP 2002-34905 20020213
SO PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined Applications, Vol. 2003
IC ICM C25D013-06
ICS C09D005-44; C09D163-00; C09D175-04
AB PROBLEM TO BE SOLVED: To provide a method of forming a electrodeposition coating film which has excellent uniform coating property to improve film forming property on an inside part while suppressing the film thickness of an outside plate in a material to be coated which has a bag like structure and a coated product.
SOLUTION: A. In the method of forming an electrodeposition coating film, the quantity (a) of electricity required to start the deposition of the coating film is 100-400 C/m² in a electrodeposition coating with a cationic electrodeposition coating material. B. The polarity resistance (b) per unit film thickness is 50-300 kΩ.cm²/μm in the method of forming the electrodeposition coating film in the electrodeposition coating with the cationic electrodeposition coating material.
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